



"Express Mail" Label No. EV 154333565 US

Date of Deposit July 26, 2002

PATENT  
Attorney Docket No.: 00939B-078800US  
Client Ref. No.: 2000-OPH-2014/EYL

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Assistant Commissioner for Patents  
Washington, D.C. 20231

By: Bonnie Pickles

*7/26/02*

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re application of:

Jae Chang JUNG et al.

Application No.: 09/728,535

Filed: December 1, 2000

For: OVER-COATING COMPOSITION  
FOR PHOTORESIST, AND  
PROCESSES FOR FORMING  
PHOTORESIST PATTERNS USING  
THE SAME

Examiner: Cynthia Hamilton

Art Unit: 1752

AMENDMENT

RECEIVED  
AUG 01 2002  
TC 1700

Assistant Commissioner for Patents  
Washington, D.C. 20231

**AMENDMENT AND RESPONSE**

This responds to the Office Action having a mailing date of May 1, 2002.

IN THE CLAIMS:

Please amend Claims 1, 6, 9-11, and 15 as follows:

*Sub 1*

1. (Amended Herein) An over-coating composition for coating a photoresist composition to provide a vertical photoresist pattern, said over-coating composition comprising an over-coating resin derived from acrylic acid, alkyl acrylate, or a mixture thereof, a solvent, and a basic compound.

07/30/2002 NMOHAMM1 00000119 201430 09728535

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